country) working in the candidate's field of specialization. (vi) An explanatory note (200 words) on the likely benefit to the candidate, with specific reference to the development of future research and development work to be carried out by him in the same field and its relevance to the country's development. Completed applications should be mailed so as to reach the COSTED Secretariat at least three months before the starting date of the proposed programme.

Book Reviews

Works intended for notice in this column should be sent direct to the Book-Review Editor (M. M. Woolfson, Physics Department, University of York, Heslington, York YO1 5DD, England). As far as practicable books will be reviewed in a country different from that of publication.

Electronic absorption and internal and external vibrational data of atomic and molecular ions doped in alkali halide crystals. By S. C. Jain, A. V. R. Warrier and S. K. Agarwal. Pp. 59. Springfield, Mass.: U.S. Department of Commerce, 1974. Price \$ 0.95.

Spectral data for more than 70 atomic and molecular ions when incorporated in the lattice of alkali halide crystals are tabulated in this useful inclusion in the *National Standard Reference Data System series*. 55 tables are given in three sections, the first of which is devoted to electronic absorption wavelengths. The second gives the vibrational frequencies of the internal modes of complex ions whilst the third deals with external vibrational frequencies.

Each table gives the wavelength associated with the particular absorptive process for each centre in a number of alkali halides together with a group-theoretical assignment for the transition.

The data that appear in the tables were selected on the basis of consistency amongst different authors.

This relatively cheap publication will provide a useful addition to the library of solid state spectroscopists.

D. W. GOODWIN

Department of Physics University of York Heslington York YO1 5DD England Silicon carbide—1973. (Proceedings of the Third International Conference, Florida, 1973.) Edited by R. C. Marshall, J. W. Faust Jr & C. E. Ryan. Pp.xii + 692, Figs. and plates 423, Tables 53. Columbia: Univ. of South Carolina Press, 1974. Price \$25 00.

Though the growth of silicon carbide has been studied for many years, it was only 16 years ago that a paper presented at a solid-state conference in Brussels. on the growth properties and potential of single-crystal SiC was received with considerable enthusiasm. So much so that in the following April a full conference was devoted to the material. It was not until 1968, when many of the technical problems were realized, that a further conference was devoted to SiC. The many advances that have been made since then are reflected in this collection of the 75 papers presented at the 1973 Miami Conference.

Although SiC was at first regarded solely as a semiconductor of considerable potential in the device field, its possible applications now range far, exploiting its refractory nature, chemical inertness, high tensile strength and high forbidden energy gap. The editors have accordingly arranged the conference papers into five distinct sections. Part I is devoted to the growth of SiC by various techniques associated with potential applications. Six papers each are devoted to expitaxic growth and vapour-phase deposition; a further paper describes new techniques. Both Laue and oscillation techniques are used to illustrate crystal quality and this section will be of interest to inorganic crystallographers. Other papers deal with growth kinetics and inclusion problems.

Part II is devoted to the study of polytypes which were discovered over sixty years ago. They are believed to be formed by molecular complexity at high growth temperatures. The use of etch pits to show up some polytypes is discussed and an atlas of the Laue patterns of known polytypes given. Other papers discuss solid-state transformations and evidence for a new 21-layer trigonal polytype.

The third part, concerned with physical properties, begins with a complete review of optical studies followed by papers on band structure calculations for polytypes. These are followed by reviews of both photo- and cathodoluminescence of polytypes.

The last two parts are devoted to nonelectronic and electronic applications. The first group utilize the high tensile strength and moduli of SiC and include armour plating and the use of fibres with strengths as high as 4700MN m⁻². Other papers relate to the corrosion resistance of SiC when used as resistive heating elements. The last part deals with electronic applications, particularly as light-emitting diodes with brightnesses between 10 and 100 nits and with spectral emission in the blue to red. SiC cold cathodes with emissions of 200 μ A cm⁻² are also fully discussed. Further papers discuss materials such as Be₃P₂, Be₃C and Si₃N₄ which might develop into more useful materials than SiC.

Solid-state physicists with an interest in new materials with diverse applications will find this collection of papers of considerable interest. The book has been offset without reduction in size and is therefore a tome of massive dimensions, but one which should be read.

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Low energy electron diffraction. The theory and its application to determination of surface structure. By J. B. Pendry. New York: Academic Press, 1974. Price: £8.60; \$22.25.

The study of low-energy electron diffraction (LEED) started in 1927 with the historic experiments of Davisson and Germer and their demonstration of the wave nature of the electron. It continued quietly with the studies of Farnsworth who was able to complete a remarkable amount of experimental work before the appropriate ultra-high vacuum technology was widely available. In the early 1960's LEED activity expanded rapidly all over the world largely because of the commercial availability of the appropriate apparatus and a widespread interest in the possibility of determining the atomic structure within the top few atomic monolayers of a solid. Although the strong scattering cross sections of atoms for low-energy electrons were widely appreciated at that time, the im-